# Disital Versatile Disk (DVD)

It has much more storage capacity than that if CD. It uses have beam if shorter wavelength as compared to that used in CDs. The capacity of different types of large capacity optical disks as as follows:

DVD-ROM: 4.7, 8.5 and 17 GB, for single sided single Layer, single sided double Layer and double sided double Layer respectively.

DVO-R: 4.76B and 8.56B, for single Layer and double Layer respectively.

DVD-RW: 4.7 GB and 9.4 GB, for Single Layer and double Layer respectively.

Blu-ray disk: 25 GB and 50 GB, for single Layer and double Layer respectively.

### Blu-Ray DISKS :-

The eapacity of this type of disks is 25 GB and 50 GB for Bruger Layer and double layer disks respectively.

Blu-ray disks are available in two sizes! Standard (12 cm) and Mini (8cm). Each disk can have either a single Layer or dual Layers depending upon which the data Storage capacity of the disk differs.

Lés data transfer rate is 72 1960s. In future much histoer data transfer speed is expected.

## Advantages of Optical DISKS

The main advantages of optical disks are as

- (1) They Possess Lurge expactity to store data linformation in the form of multimedia, graphics and video files.
- (ii) The Life span for data storage in optical disks is considered to be more, about 10-20 years as compared to magnetic disks.
- Other Storage media; therefore, they have lew cost per bit of storage.

(iv) Due to their small size and lightweight, there disks are easily portable and stored.

# Disadventages of Optical Bisks.

- (i) They possess slow doesn access speed as compared to the magnetic disks.
- (1') The drive mechanism of optical disk is more compricated than the magnetic and floppy disks.

### CCD Memory

Semi-conductor device. It stores the information in the semi-conductor device. It stores the information in the form of charge. It is following ted in the form of Longshift register to act as a memory. There is a p-type substrate. On the p-type substrate. On the p-type substrate on the p-type substrate. On the p-type substrate, there is an oxide Larger which acts as an insulating Larger. On the oxide Larger, there is an isolated

gates. When positive potential is applied to a gate with the substrate, a potential well is developed under the gate. In this condition, if a charge of electron is injected into the region under the gate, the charge is retained their It a segmence of clock pulsos is applied to the gates, the stoned charge shifts along the region under the next gate

For the use of eCDs for compriser's version, several hundred eCD shift registers are fabricated in parallel on a single IC. A Photodiode is fabricated under the alternate gate. To event Potential well, all the gates having Photodiodes under them are made positive. When wisht falls on Photodiode a charge proportional to the intensity of light is produced. The charge is held in each well. These charges can be shifted.

#### Cache Memory:

It is a semi-conductor memory and is Placed byw the CPU and the main memory at counst of static RA175. It's access time is about 10 ns which is much less than that of main memory. It's corpority is 2 to 3 percent of that of main memory. It stores instruction codes and data which are to be immediately used by the CPU.

The modern 32-bort and 64 bort microprocessors operates at very high speed. Their clock rates are in the rouge of 400 1942 to 3.86042. The memory matching with high speed microprocessor must be very fast. But very fust memory is very expensive. If a fast microprocessor operates with conventional main memory, 24 has to operate with several wait states. This will reduce the speed of the computer. A compromise is made and a high speed eache memory is used to supply currently needed instructions and data to CPU. The main memory stores program and data which is to be processed by CPU. The currently needed instructions and data of the program are headed into the cache from the main memory.